

RCE

**REQUEST
FOR
CONTINUED EXAMINATION (RCE)
TRANSMITTAL**

MAIL STOP RCE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450



Subsection (b) of 35 U.S.C. § 132, effective on May 29, 2000,
provides for continued examination of an utility or
plant application filed on or after June 8, 1995

Application Number	10/084,204
Confirmation Number	6177
Filing Date	February 28, 2002
First Named Inventor	Takako SUZUKI
Group Art Unit	1752
Examiner Name	John S. Y. Chu
Matter Number	Q67844

Title

**POSITIVE PHOTORESIST COMPOSITION
AND PROCESS FOR FORMING RESIST
PATTERN USING SAME**

This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application.

1. SUBMISSION REQUIRED UNDER 37 C.F.R. § 1.114

- a. ☐ Previously submitted
- i. ☐ Please enter and consider the amendment(s)/reply under 37 C.F.R. § 1.116
previously filed on _____
- ii. ☐ Consider the arguments in the Appeal Brief or Reply Brief previously filed on _____
- iii. ☐ Other _____
- b. ☒ Enclosed
- i. ☒ Amendment/Reply
- ii. ☐ Affidavit(s)/Declaration(s)
- iii. ☒ Information Disclosure Statements (IDS)
- iv. ☒ Petition for Extension of Time
- v. ☐ Other _____

2. MISCELLANEOUS

- a. ☐ Suspension of action on the above-identified application is requested under 37 C.F.R. § 1.103(c) for a
period of _____ Months
- b. ☐ Other _____

3. FEES

Checks for the RCE statutory fee of \$770.00 and for the Petition for Extension of Time statutory fee (for one
(1) month) of \$110.00 are attached. The USPTO is directed and authorized to charge all required fees, except for the
Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said
Deposit Account. A duplicate copy of this transmittal letter is attached.

CORRESPONDENCE ADDRESS

Direct all correspondence to the address for SUGHRUE MION, PLLC filed under the Customer Number listed below:

09/21/2004 HVUONG1 00000059 10084204

01 FC:1801

770.00 0P

WASHINGTON OFFICE

23373

CUSTOMER NUMBER

SIGNATURE OF ATTORNEY

Name Patrick F. Gallagher Registration No. 54,109

Signature Date September 20, 2004



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q67844

Takako SUZUKI, et al.

Appln. No.: 10/084,204

Confirmation No.: 6177

Group Art Unit: 1752

Filed: February 28, 2002

Examiner: John S. Y. Chu

For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING RESIST
PATTERN USING SAME

AMENDMENT UNDER 37 C.F.R. § 1.114(c)

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Alexandria, VA 22313-1450

Sir:

A RCE and Petition for Extension of Time (for one (1) month) is filed concurrently herewith, thus extending the time for responding to the Final Office Action of May 18, 2004, from August 18, 2004, to September 20, 2004 (September 18, 2004 being a Saturday). Please amend the above-identified application as follows:

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